

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

Edward Y. CHANG et al.

Confirmation No: 4041

Appl. No.

10/699.839

Filed

: November 4, 2003

Title

: GROWTH OF GaAs EPITAXIAL LAYERS ON SI SUBSTRATE

BY USING A NOVEL GeSi BUFFER LAYER

TC/A.U.

: 2818

Examiner

: M. H. C. Tran

Docket No.:

: CHAN3228/REF

Customer No:

: 23364

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of October 7, 2005, in connection with the above identified application.

The Official Action is a restriction requirement in which it is urged that there are two separate and distinct species claimed in this application. Applicants elect the Group I species which includes claims 1-13, without traverse. Applicants reserve the right to file a divisional application on the non-elected invention at a later time.

In view of the election of the Group II invention, without traverse, an early and favorable action on the merits is now believed to be in order and is most respectfully requested.

Respectfully submitted, BACON & THOMAS, PLLC

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REF/SAB

ResponsetoRestrictRequirement2.wpd November 7, 2005